

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Seetharaman Sridhar

Docket No.: TI-31408

Serial No: TBD

Examiner: TBD

Filed: 11/08/01

Art Unit: TBD

For: PROCESS TO IMPROVE NWEILL-NWEILL ISOLATION WITH A  
BLANKET LOW DOSE HIGH ENERGY IMPLANT

*2/Prea  
J. Step two  
3-2-02*

PRELIMINARY AMENDMENT

November 8, 2001

Assistant Commissioner for Patents

Washington, DC 20231

Dear Sir:

Please amend the above referenced application as follows:

In the Specification:

Page 1, before line 1, insert --This application claims priority under 35 USC §

119(e)(1) of provisional application number 60/259,298 filed 12/31/00--

10005785-110601  
T09011-52/50001

*a*